

Introduction to CMOS VLSI Design

Circuits & Layout

Outline

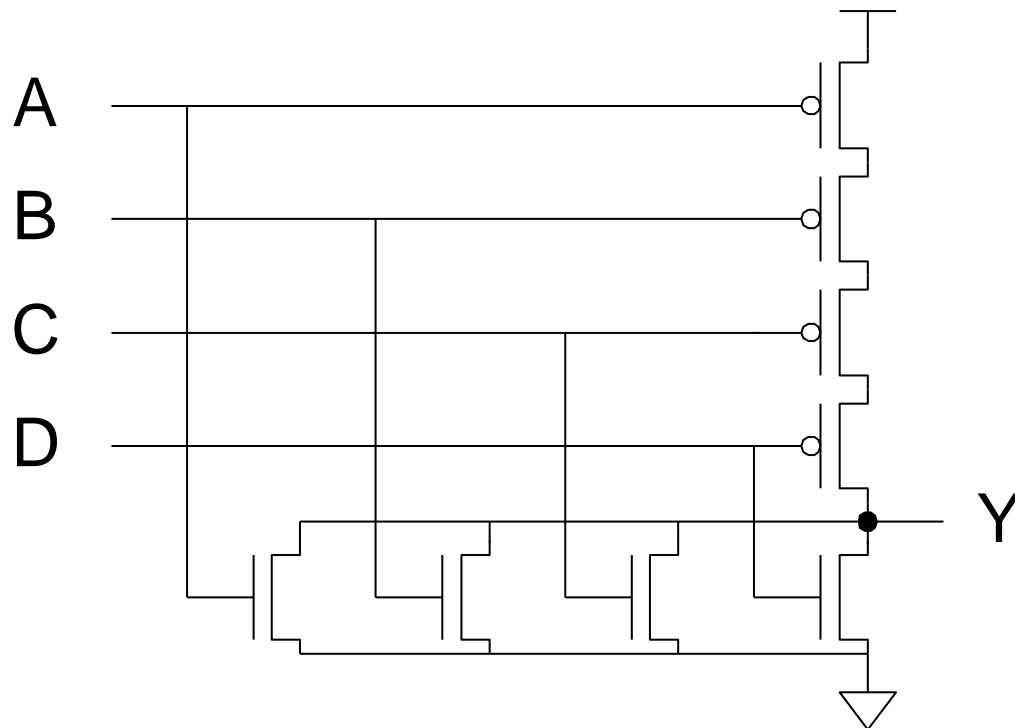
- ❑ CMOS Gate Design
- ❑ Pass Transistors
- ❑ CMOS Latches & Flip-Flops
- ❑ Standard Cell Layouts
- ❑ Stick Diagrams

CMOS Gate Design

- Activity:
 - Sketch a 4-input CMOS NAND gate

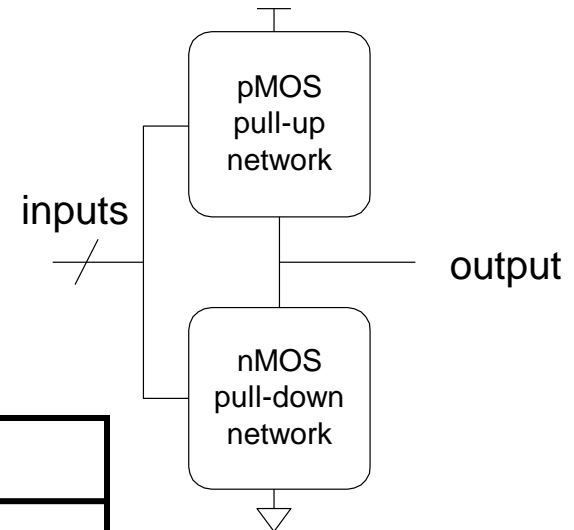
CMOS Gate Design

- Activity:
 - Sketch a 4-input CMOS NOR gate



Complementary CMOS

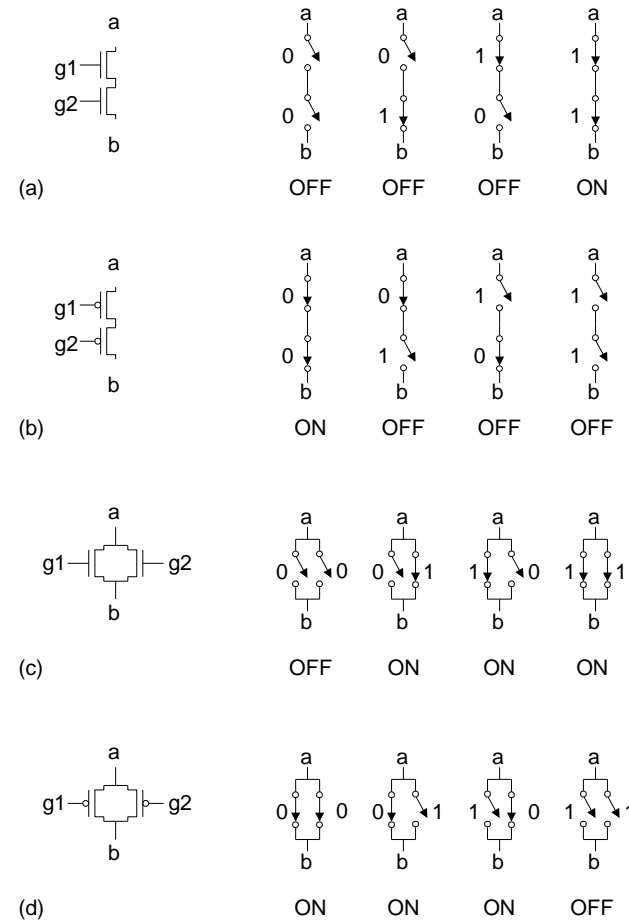
- ❑ Complementary CMOS logic gates
 - nMOS *pull-down network*
 - pMOS *pull-up network*
 - a.k.a. static CMOS



	Pull-up OFF	Pull-up ON
Pull-down OFF	Z (float)	1
Pull-down ON	0	X (crowbar)

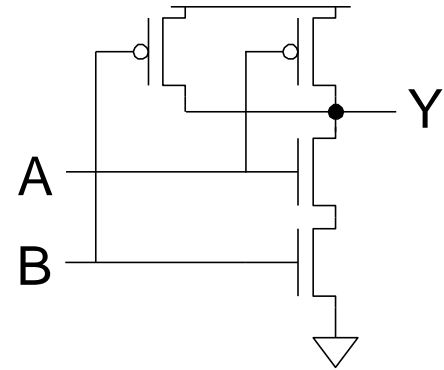
Series and Parallel

- ❑ nMOS: 1 = ON
- ❑ pMOS: 0 = ON
- ❑ *Series*: both must be ON
- ❑ *Parallel*: either can be ON



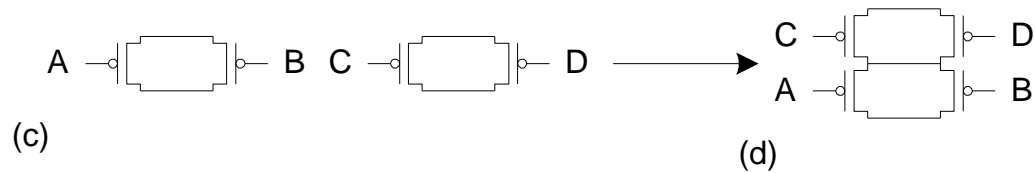
Conduction Complement

- ❑ Complementary CMOS gates always produce 0 or 1
- ❑ Ex: NAND gate
 - Series nMOS: $Y=0$ when both inputs are 1
 - Thus $Y=1$ when either input is 0
 - Requires parallel pMOS
- ❑ Rule of *Conduction Complements*
 - Pull-up network is complement of pull-down
 - Parallel \rightarrow series, series \rightarrow parallel



Compound Gates

- ❑ *Compound gates can do any inverting function*
- ❑ Ex: $Y = (A.B + C.D)'$

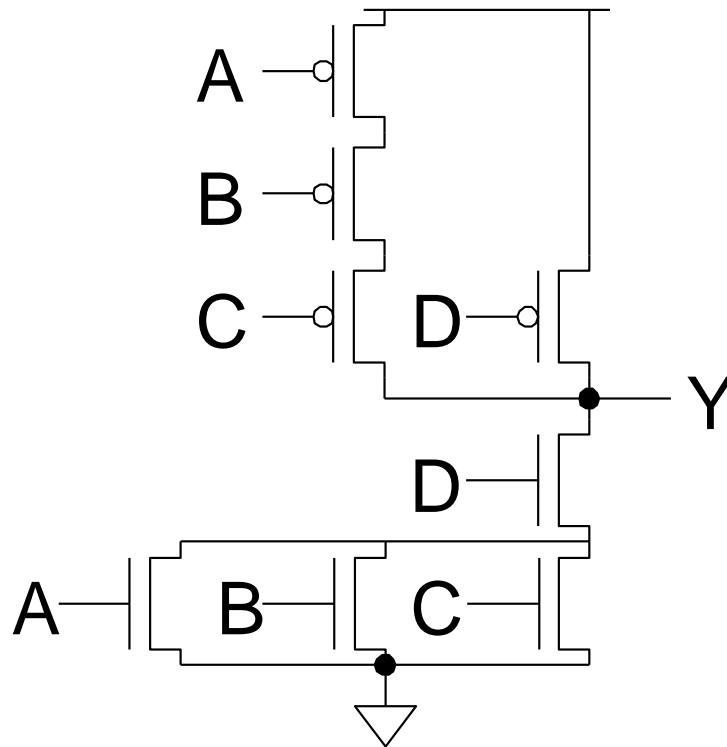


Example: 03AI

$$\square Y = ((A+B+C).D)'$$

Example: O3AI

$$\square Y = ((A+B+C).D)'$$

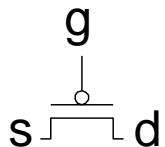
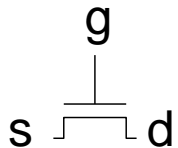


Signal Strength

- ❑ *Strength* of signal
 - How close it approximates ideal voltage source
- ❑ V_{DD} and GND rails are strongest 1 and 0
- ❑ nMOS pass strong 0
 - But degraded or weak 1
- ❑ pMOS pass strong 1
 - But degraded or weak 0
- ❑ Thus nMOS are best for pull-down network

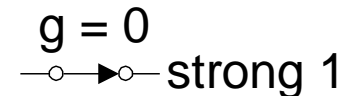
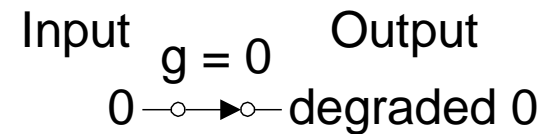
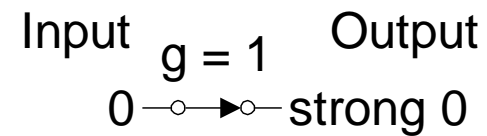
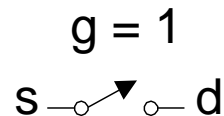
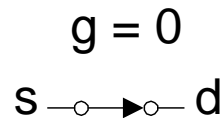
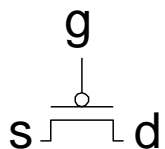
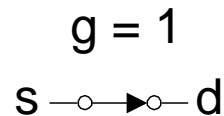
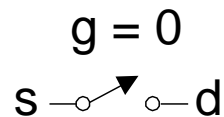
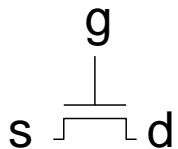
Pass Transistors

- ❑ Transistors can be used as switches



Pass Transistors

□ Transistors can be used as switches

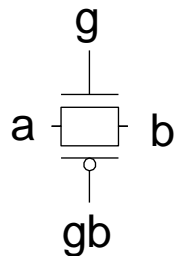


Transmission Gates

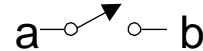
- ❑ Pass transistors produce degraded outputs
- ❑ *Transmission gates* pass both 0 and 1 well

Transmission Gates

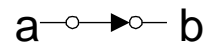
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$g = 0, gb = 1$



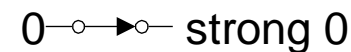
$g = 1, gb = 0$



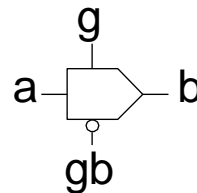
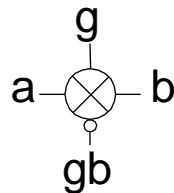
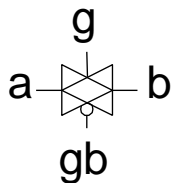
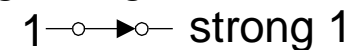
Input

Output

$g = 1, gb = 0$



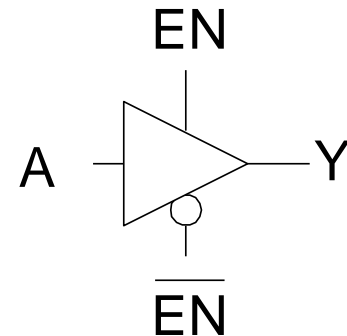
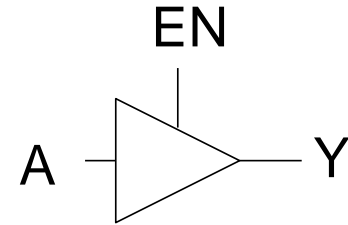
$g = 1, gb = 0$



Tristates

- ❑ *Tristate buffer* produces Z when not enabled

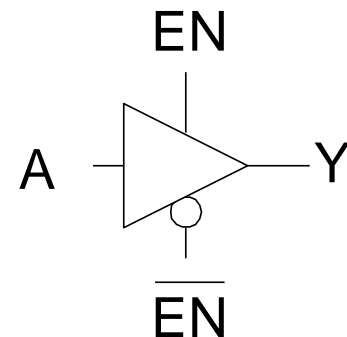
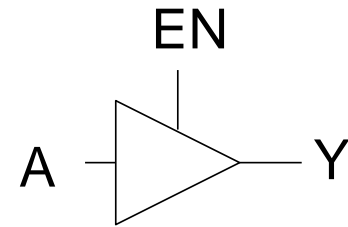
EN	A	Y
0	0	
0	1	
1	0	
1	1	



Tristates

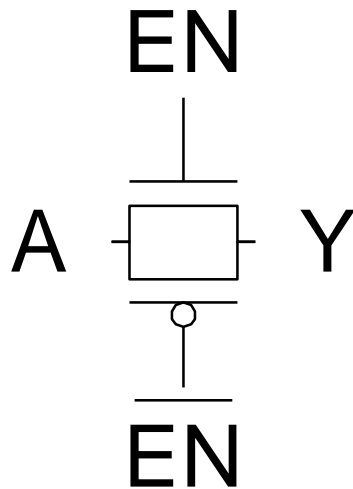
- ❑ *Tristate buffer* produces Z when not enabled

EN	A	Y
0	0	Z
0	1	Z
1	0	0
1	1	1



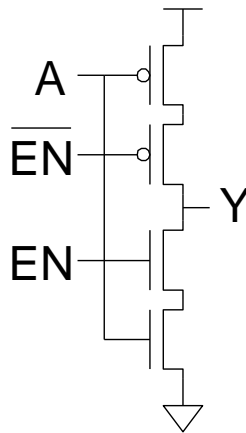
Nonrestoring Tristate

- ❑ Transmission gate acts as tristate buffer
 - Only two transistors
 - But *nonrestoring*
 - Noise on A is passed on to Y



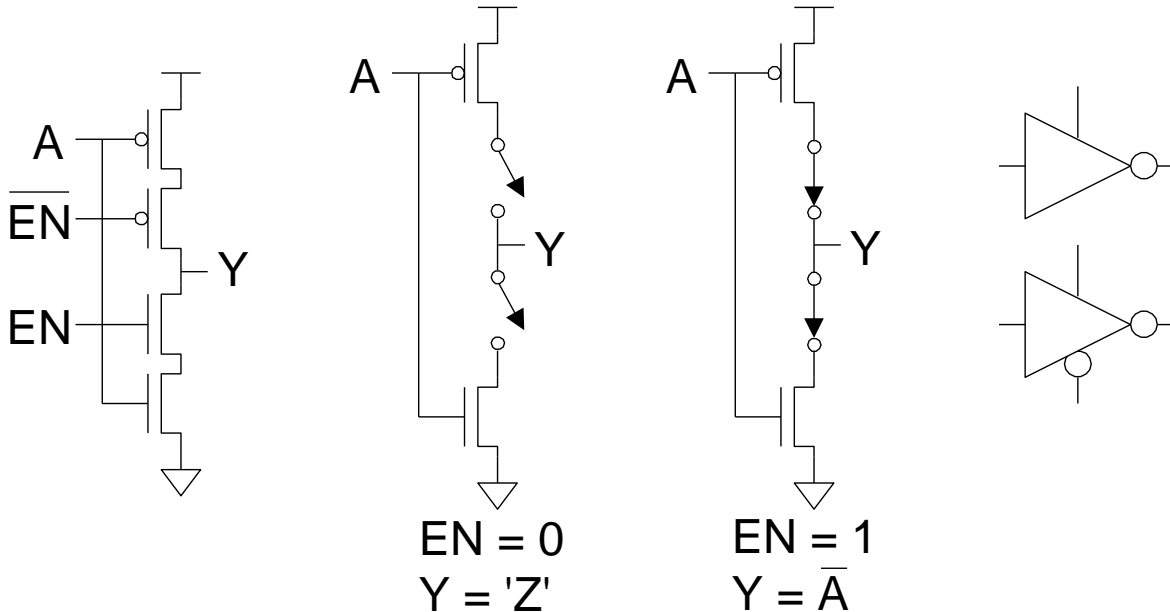
Tristate Inverter

- ❑ Tristate inverter produces restored output
 - Violates conduction complement rule
 - Because we want a Z output



Tristate Inverter

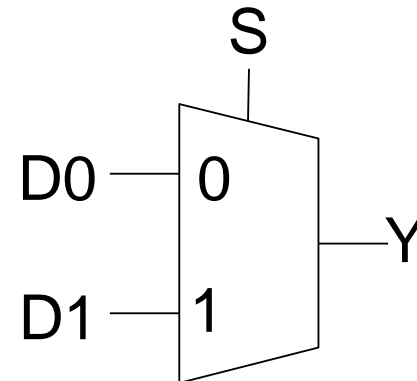
- ❑ Tristate inverter produces restored output
 - Violates conduction complement rule
 - Because we want a Z output



Multiplexers

- ❑ 2:1 *multiplexer* chooses between two inputs

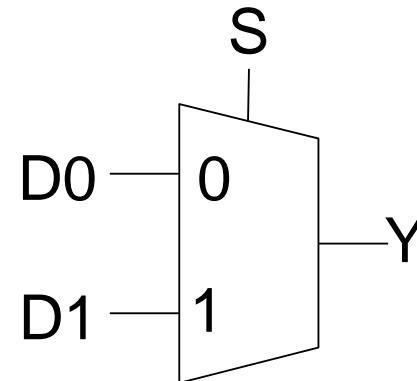
S	D1	D0	Y
0	X	0	
0	X	1	
1	0	X	
1	1	X	



Multiplexers

- ❑ 2:1 multiplexer chooses between two inputs

S	D1	D0	Y
0	X	0	0
0	X	1	1
1	0	X	0
1	1	X	1

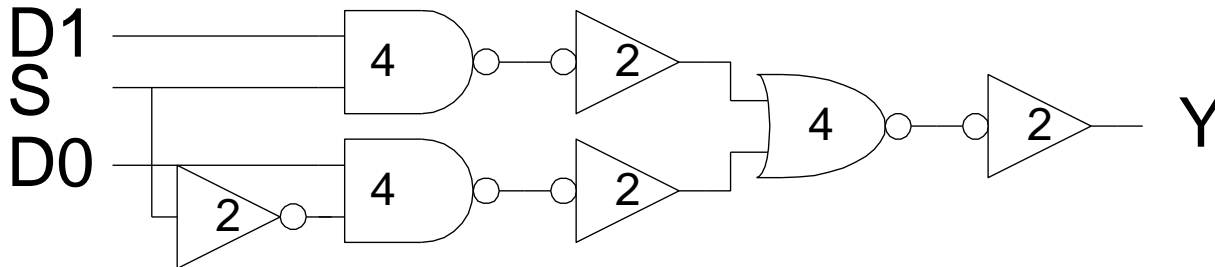
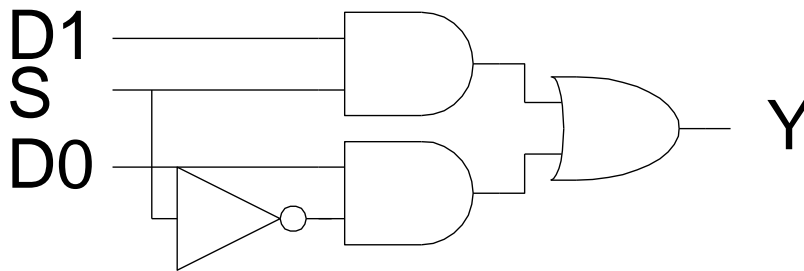


Gate-Level Mux Design

- ❑ $Y = SD_1 + \bar{S}D_0$ (too many transistors)
- ❑ How many transistors are needed?

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- ❑ How many transistors are needed? 20

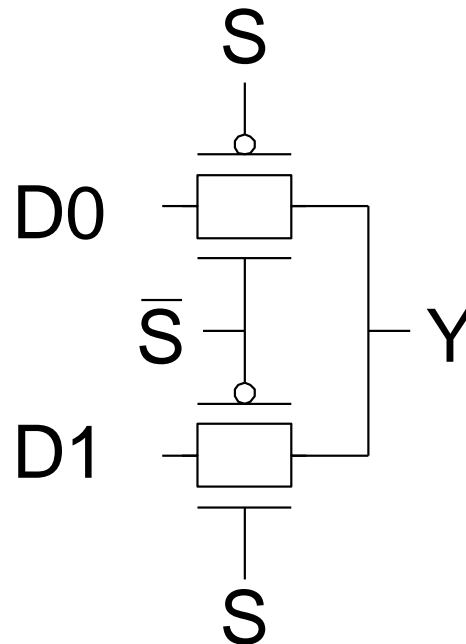


Transmission Gate Mux

- ❑ Nonrestoring mux uses two transmission gates

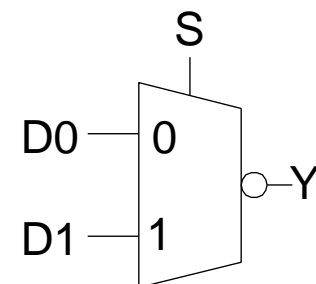
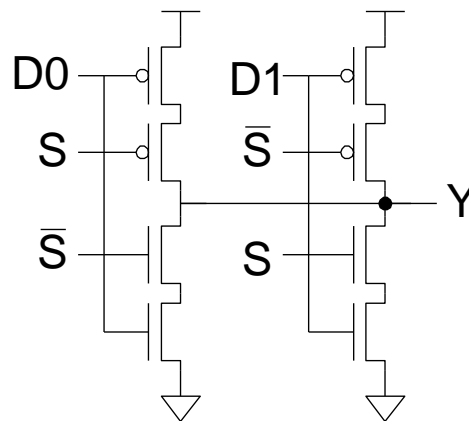
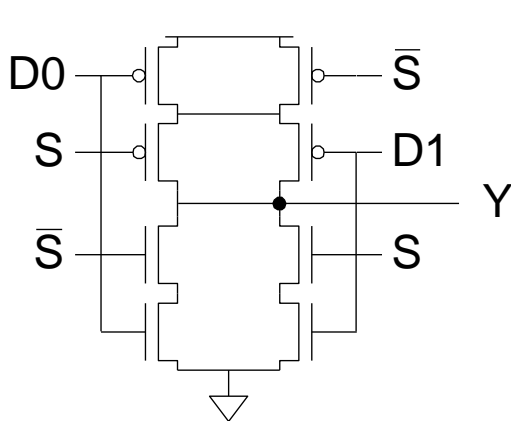
Transmission Gate Mux

- ❑ Nonrestoring mux uses two transmission gates
 - Only 4 transistors



Inverting Mux

- ❑ Inverting multiplexer
 - Use compound AOI22
 - Or pair of tristate inverters
 - Essentially the same thing
- ❑ Noninverting multiplexer adds an inverter

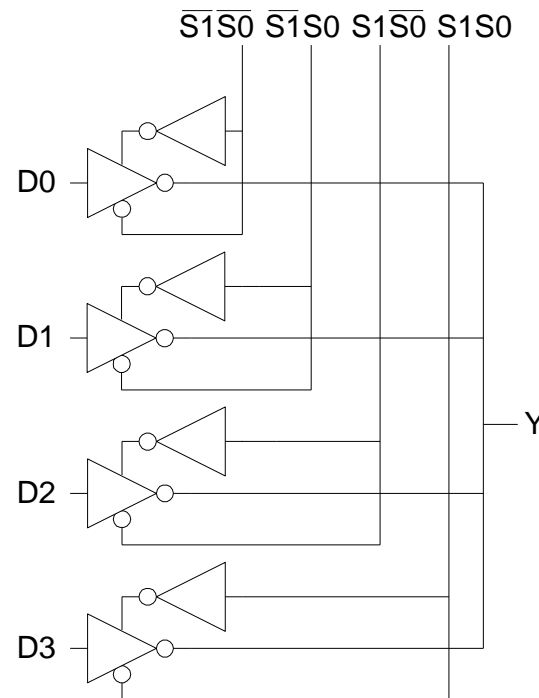
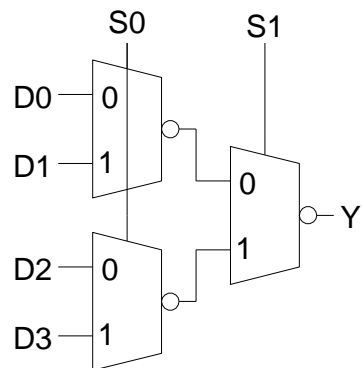


4:1 Multiplexer

- ❑ 4:1 mux chooses one of 4 inputs using two selects

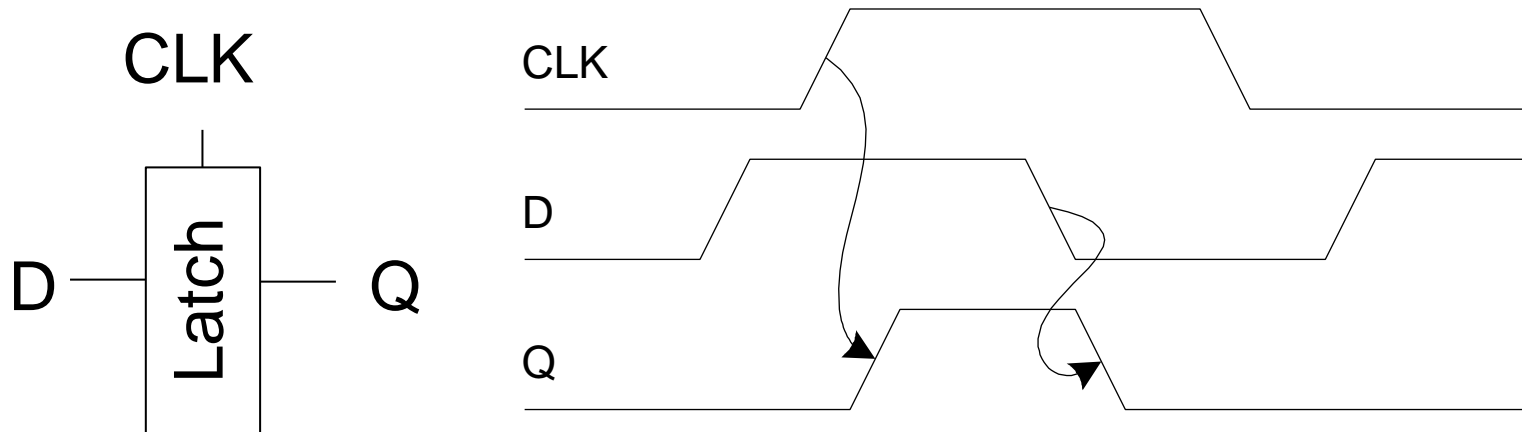
4:1 Multiplexer

- ❑ 4:1 mux chooses one of 4 inputs using two selects
 - Two levels of 2:1 muxes
 - Or four tristates



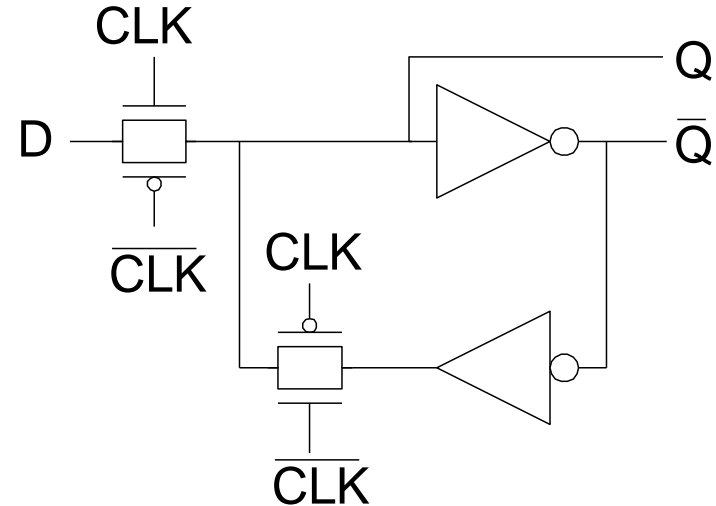
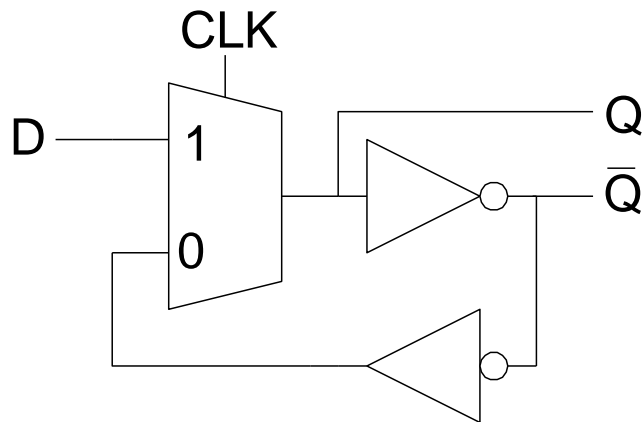
D Latch

- ❑ When $CLK = 1$, latch is *transparent*
 - D flows through to Q like a buffer
- ❑ When $CLK = 0$, the latch is *opaque*
 - Q holds its old value independent of D
- ❑ a.k.a. *transparent latch* or *level-sensitive latch*

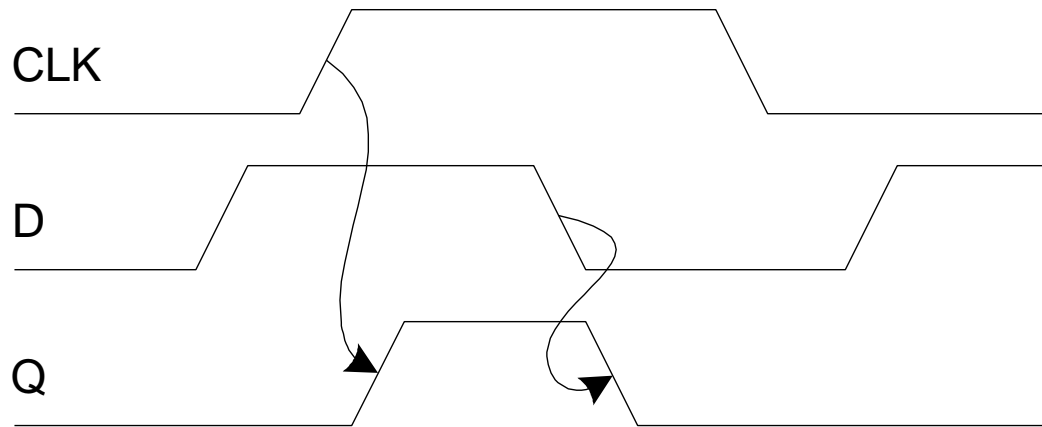
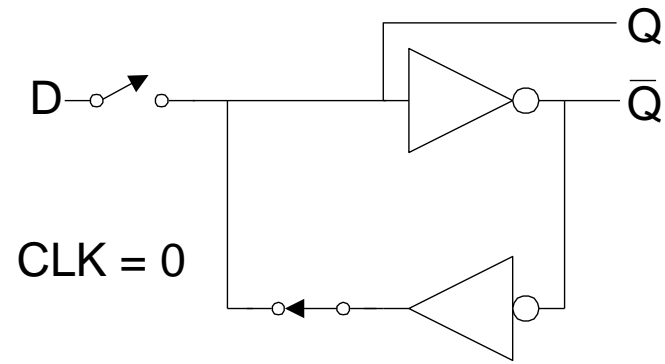
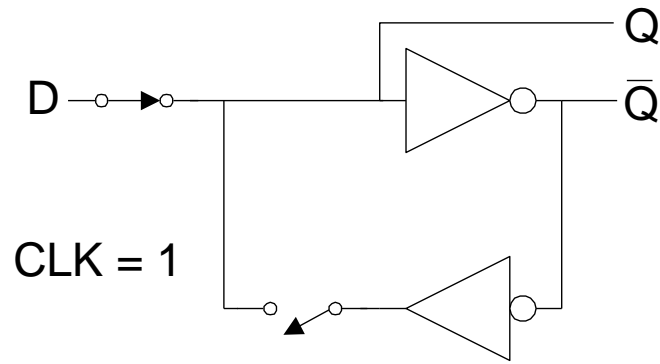


D Latch Design

- ❑ Multiplexer chooses D or old Q

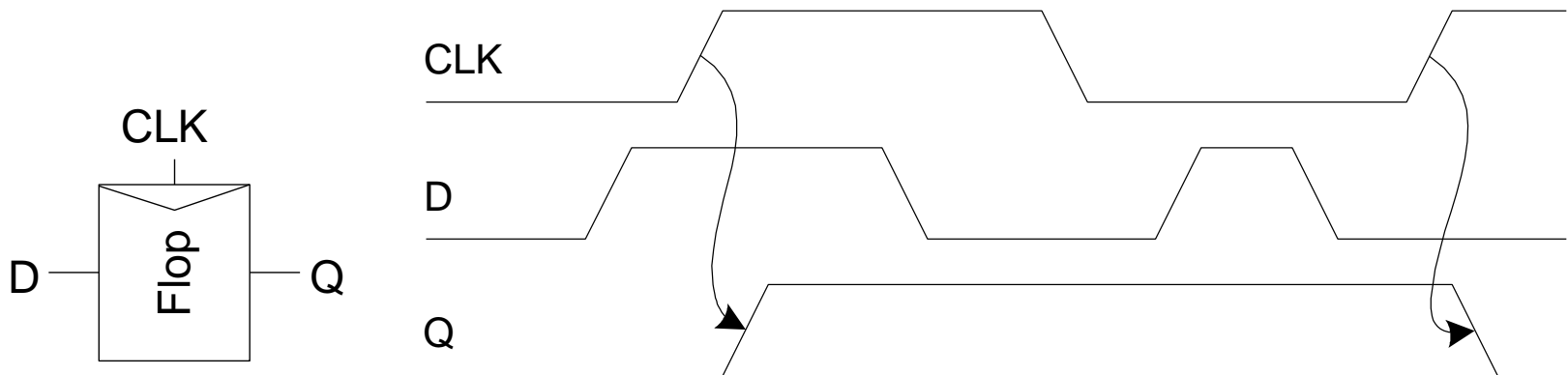


D Latch Operation



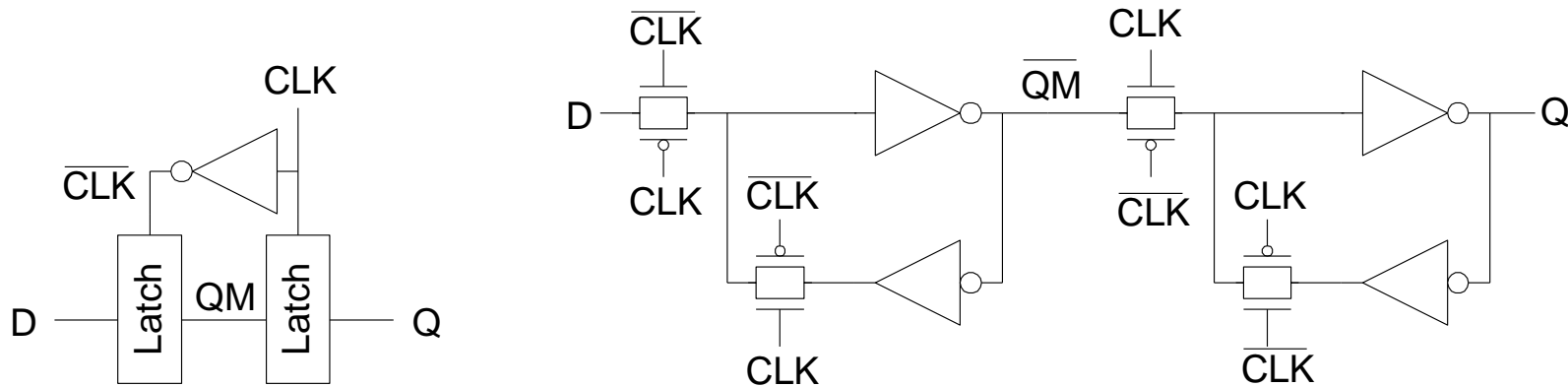
D Flip-flop

- ❑ When CLK rises, D is copied to Q
- ❑ At all other times, Q holds its value
- ❑ a.k.a. *positive edge-triggered flip-flop, master-slave flip-flop*

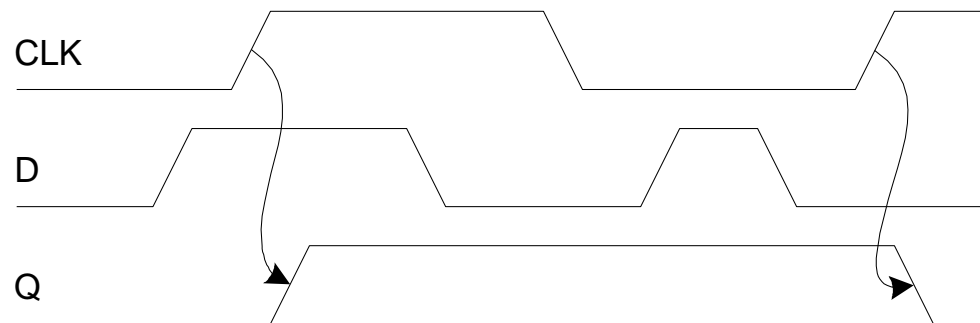
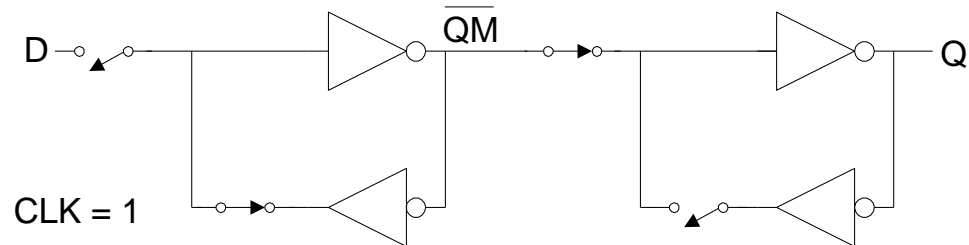
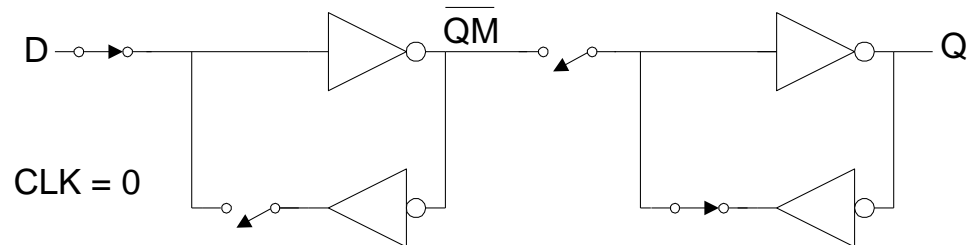


D Flip-flop Design

- ❑ Built from master and slave D latches

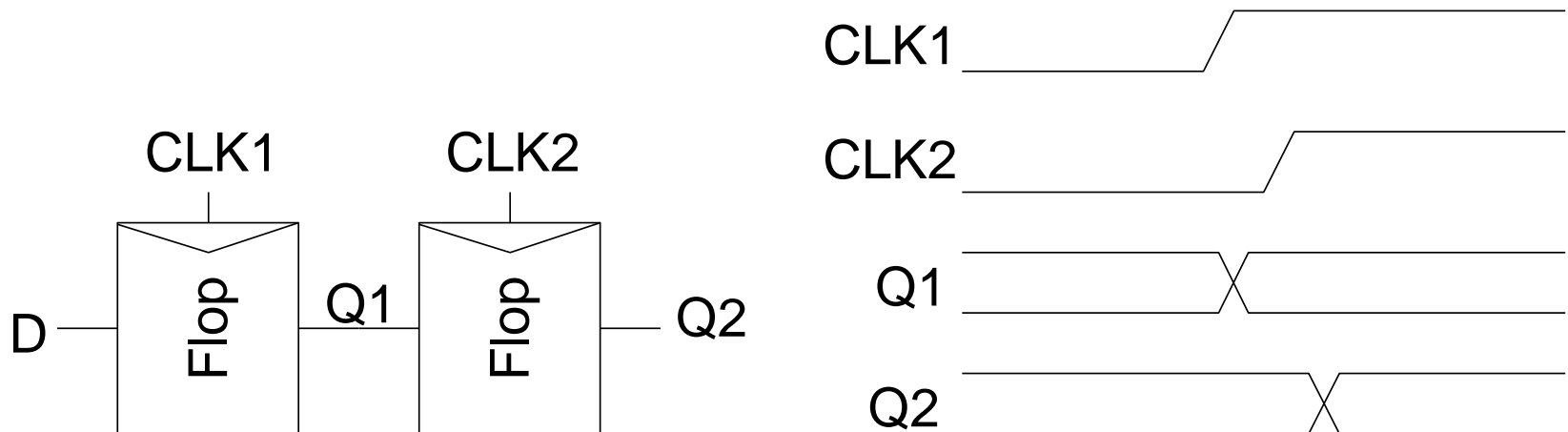


D Flip-flop Operation



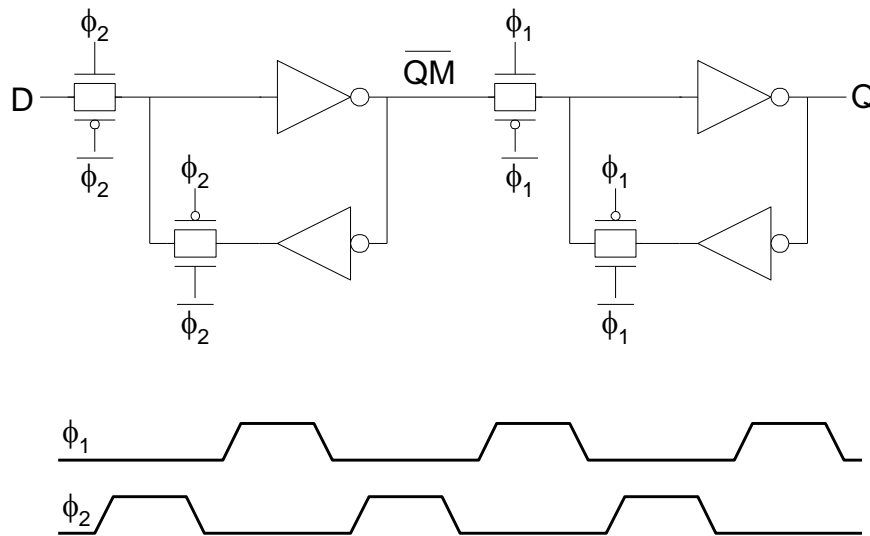
Race Condition

- ❑ Back-to-back flops can malfunction from clock skew
 - Second flip-flop fires late
 - Sees first flip-flop change and captures its result
 - Called *hold-time failure* or *race condition*



Nonoverlapping Clocks

- ❑ Nonoverlapping clocks can prevent races
 - As long as nonoverlap exceeds clock skew
- ❑ We will use them in this class for safe design
 - Industry manages skew more carefully instead

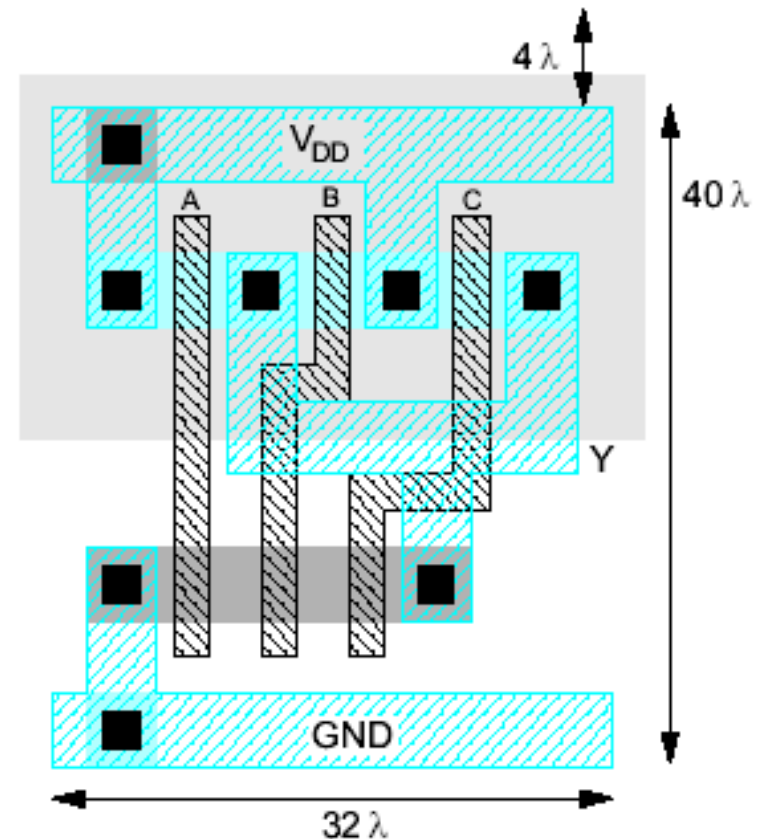


Gate Layout

- ❑ Layout can be very time consuming
 - Design gates to fit together nicely
 - Build a library of standard cells
- ❑ Standard cell design methodology
 - V_{DD} and GND should abut (standard height)
 - Adjacent gates should satisfy design rules
 - nMOS at bottom and pMOS at top
 - All gates include well and substrate contacts

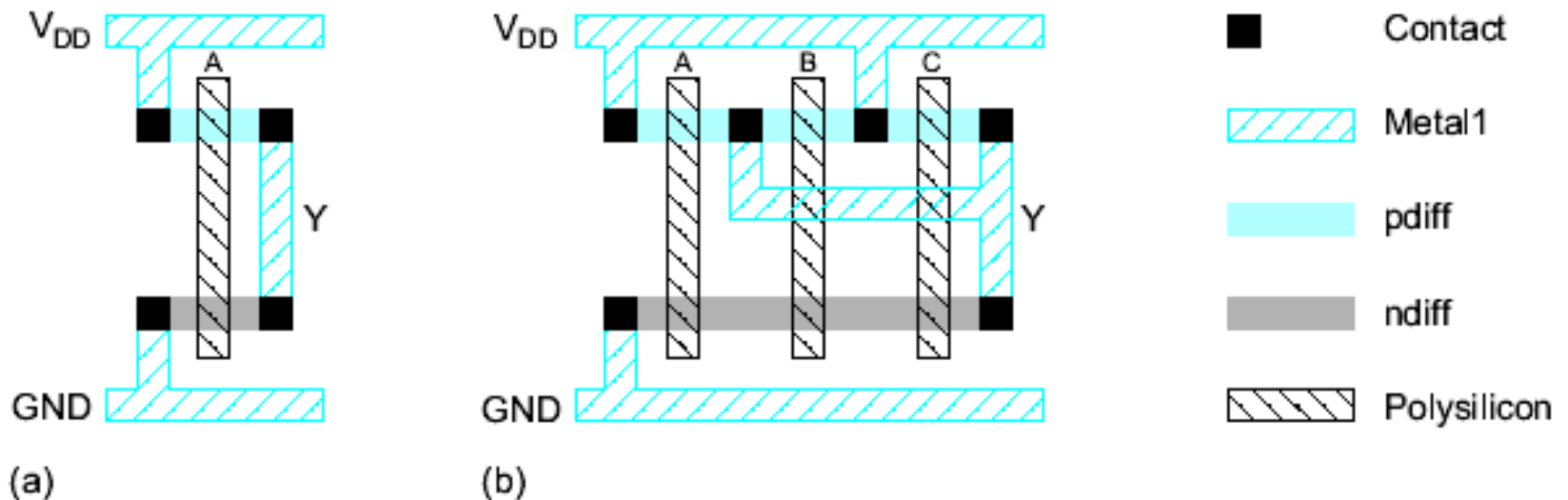
Example: NAND3

- ❑ Horizontal N-diffusion and p-diffusion strips
- ❑ Vertical polysilicon gates
- ❑ Metal1 V_{DD} rail at top
- ❑ Metal1 GND rail at bottom
- ❑ 32λ by 40λ



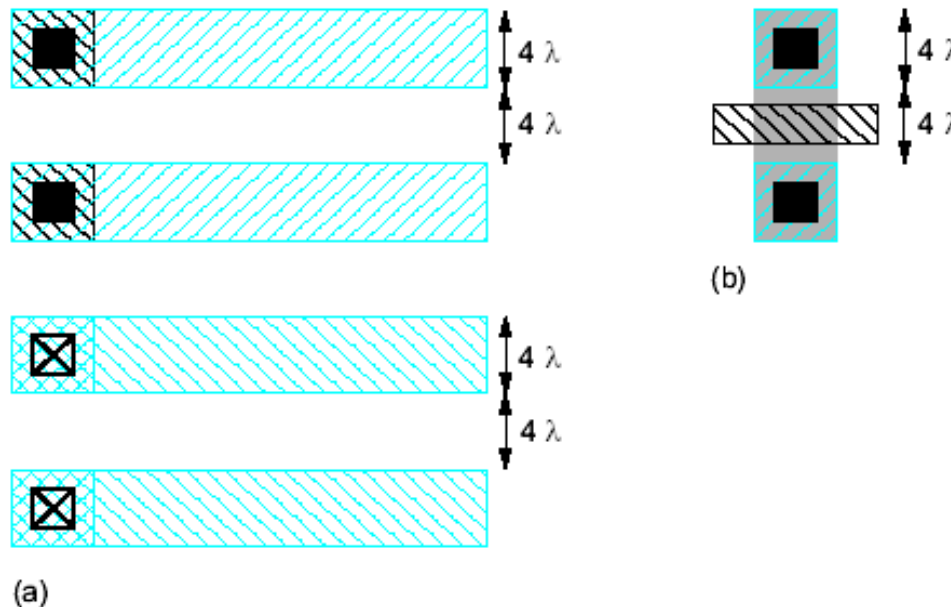
Stick Diagrams

- ❑ *Stick diagrams* help plan layout quickly
 - Need not be to scale
 - Draw with color pencils or dry-erase markers



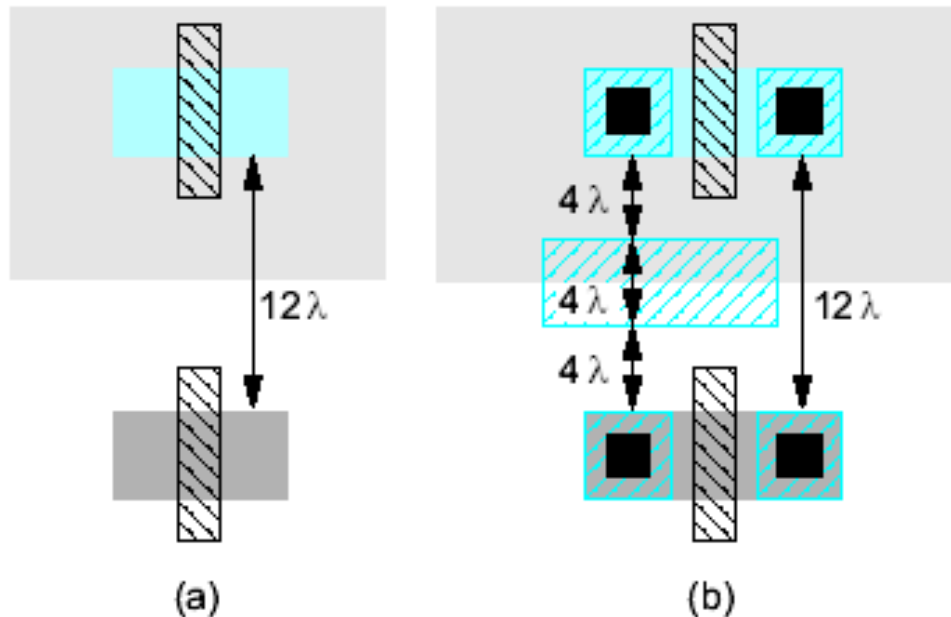
Wiring Tracks

- ❑ A *wiring track* is the space required for a wire
 - 4λ width, 4λ spacing from neighbor = 8λ pitch
- ❑ Transistors also consume one wiring track



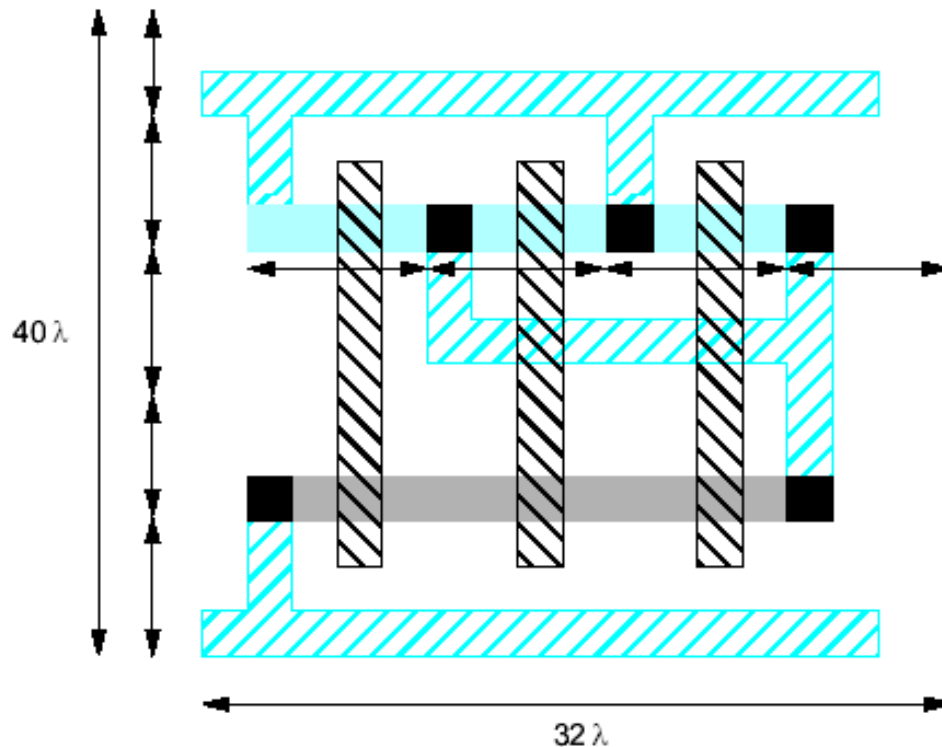
Well spacing

- ❑ Wells must surround transistors by 6λ
 - Implies 12λ between opposite transistor flavors
 - Leaves room for one wire track



Area Estimation

- ❑ Estimate area by counting wiring tracks
 - Multiply by 8 to express in λ

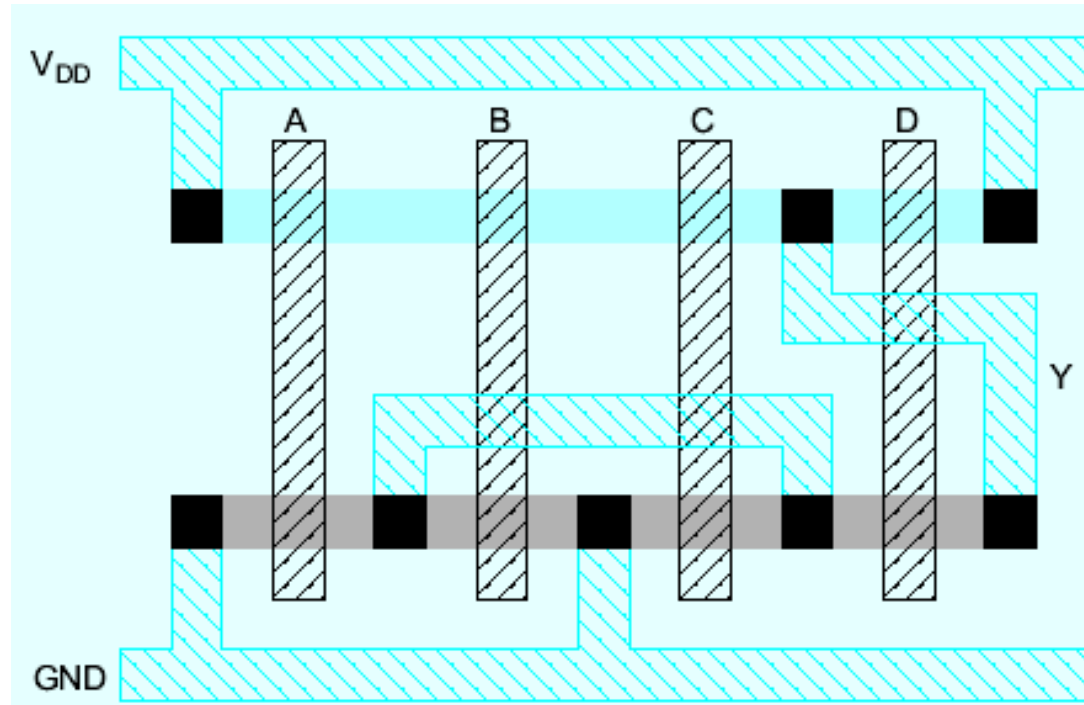


Example: O3AI

- Sketch a stick diagram for O3AI and estimate area
 - $Y = ((A+B+C).D)'$

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